

PROCEEDINGS OF SPIE

Nanoengineering: Fabrication, Properties, Optics, Thin Films, and Devices XIX

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Editors

**21–23 August 2022
San Diego, California, United States**

Sponsored and Published by
SPIE

Volume 12202

Proceedings of SPIE 0277-786X, V. 12202

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Nanoengineering: Fabrication, Properties, Optics, Thin Films, and Devices XIX, edited by Balaji Panchapakesan,
André-Jean Attias, Wounjhang Park, Proc. of SPIE Vol. 12202, 1220201 · © 2022 SPIE ·
0277-786X · doi: 10.1117/12.2661707

Proc. of SPIE Vol. 12202 1220201-1

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Please use the following format to cite material from these proceedings:
Author(s), "Title of Paper," in *Nanoengineering: Fabrication, Properties, Optics, Thin Films, and Devices XIX*, edited by Balaji Panchapakesan, André-Jean Attias, Wounghang Park, Proc. of SPIE 12202, Seven-digit Article CID Number (DD/MM/YYYY); (DOI URL).

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510653887
ISBN: 9781510653894 (electronic)

Published by
SPIE
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time)
SPIE.org
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